



HF #12823 (In)

PATENT
Attorney Docket No. TI-25250
Application No.: 09/199,829
Customer No.: 23494

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

SMITH et al.

Application No.: 09/199,829

Filed: November 25, 1998

**For: HYDROGEN PLASMA
PHOTORESIST STRIP AND
POLYMERIC RESIDUE
CLEANUP PROCESS FOR
OXYGEN-SENSATIVE
MATERIALS**

Group Art Unit: 2823

Examiner: Julio J. MALDONADO

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION

Sir:

In reply to the Final Office Action dated June 14, 2005, the period for reply having been extended for one month by a request for extension and fee payment filed concurrently herewith, please accept this Request for Reconsideration of the application:

Remarks begin on page 2 of this paper.